## Supplementary Information

# Switching of resistive memory behavior from binary to ternary logic via subtle polymer donor and molecular acceptors design 

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Figure S1. $I-V$ characteristic of the device incorporating neat OXD-7.


Figure S2. Analysis of $I-V$ characteristics for the ITO/PVK: OXD-7: $\mathrm{PBD} / \mathrm{Al}$ devices.
(a) OFF and (c) ON states for device containing $26 \mathrm{wt} \%$ of OXD-7 and $4 \mathrm{wt} \%$ of PBD.
(b) OFF and (d) ON states for device containing $20 \mathrm{wt} \%$ of OXD- 7 and $10 \mathrm{wt} \%$ of PBD.


Figure S3. Absorption edge of the optical absorption spectra of (a) OXD-7 and (b) PBD.


Figure S4. EDX spectra for (a) neat PVK, (b) PVK: 30\%OXD-7 and (c) PVK: 24\%OXD-7: PBD films.


Figure S5. Normalized UV-Vis absorption spectra of (a) neat PVK, blended PVK: OXD-7, and (b) PVK: OXD-7: PBD films spin-cast on fused silica substrates.


Figure S6. Fluorescence spectra of the (a) PVK: OXD-7 and (b) PVK: OXD-7: PBD films in the ON state under electrical biases ( $\lambda_{\mathrm{ex}}=290 \mathrm{~nm}$ ).


Figure S7. TGA thermograms of (a) PVK, (b) OXD-7 and (c) PBD under nitrogen. DSC thermal analysis of (d) PVK, (e) OXD-7 and (f) PBD under nitrogen.

Table S1. Thickness of neat and blend PVK films.

| Film | Thickness (nm $\pm$ SD) |
| :--- | :---: |
| PVK | $74.2 \pm 2.5$ |
| PVK: $25 \mathrm{wt} \%$ OXD-7 | $72.9 \pm 1.9$ |
| PVK: $30 \mathrm{wt} \%$ OXD-7 | $68.9 \pm 2.5$ |
| PVK: $40 \mathrm{wt} \%$ OXD-7 | $69.2 \pm 2.0$ |
| PVK: $26 \mathrm{wt} \%$ OXD-7: $4 \mathrm{wt} \%$ PBD | $72.2 \pm 2.3$ |
| PVK: $24 \mathrm{wt} \%$ OXD-7: $6 \mathrm{wt} \%$ PBD | $73.3 \pm 2.4$ |
| PVK: $20 \mathrm{wt} \%$ OXD-7: $10 \mathrm{wt} \%$ PBD | $71.5 \pm 2.6$ |


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